

JUN 12 2007

Application No.:10/728,135

Docket No.:JCLA12578

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Examiner: Chacko Davis, Daborah
Group Art Unit: 1756

In re PATENT APPLICATION of
Applicants : Vencent Chang et al.

Serial No. : 10/728,135

Filed : December 03, 2003

For : IMMERSION LITHOGRAPHY
PROCESS AND MASK LAYER
STRUCTURE APPLIED IN THE SAME

AMENDMENT

PRELIMINARY AMENDMENT

MAIL STOP AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Prior to the examination on merits, please amend the above-identified application as follows
and consider the following remarks.

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02 FC:1251 120.00 DA

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